2812

Applicant(s):

Vishwanathan et al.

Application No.: 09/608,537

Filed: 6/30/2000

Title: IMPROVED POLISHING PADS FOR

CHEMICAL MECHANICAL

PLANARIZATION

Attorney Docket No.: 126

Group

Group Art Unit:

2812

Examiner:

1-11-01 Payton

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents Washington, D.C. 20231

RECEIVED

OCT 19 2000

TECHNOLOGY CENTER 2800

Dear Sir:

Prior to examination, please amend the application as follows:

In the specification:

Page 1, line 2 of the text, cancel "60/207936" and insert ---- 06/207938 ----.

Page 13, line 7 of the text, cancel " 10^{0} C" and insert ---- 100^{0} C ----.

Page 13, line 8 of the text, cancel " 10^0 C" and insert --- 100^0 C ----.

Remarks

Entry of the amendment is requested to correct typographical errors.

Respectfully Submitted,

Dota

Gerald Kita

Patent Attorney

Reg. No. 24125

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